INTERNATIONAL SEARCH REPORT

International application No PCT/FR2008/001427

A. CLASSIFICATION OF SUBJECT MATTER INV. H01L21/762

According to International Patent Classification (IPC) or to both national classification and IPC

B. FIELDS SEARCHED

 $\begin{tabular}{ll} Minimum documentation searched (classification system followed by classification symbols) \\ H01L \end{tabular}$

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Electronic data base consulted during the international search (name of data base and, where practical, search terms used)

EPO-Internal, WPI Data, INSPEC

	C. DOCUMENTS CONSIDERED TO BE RELEVANT				
Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.			
Y	US 2004/235266 A1 (TONG QIN-YI [US]) 25 November 2004 (2004-11-25) page 2, paragraph 42	1-20			
Y	WU J-Y ET AL: "EFFECT OF THE WORKING GAS OF THE ION-ASSISTED SOURCE ON THE OPTICAL AND MECHANICAL PROPERTIES OF SIO2 FILMS DEPOSITED BY DUAL ION BEAM SPUTTERING WITH SI AND SIO2 AS THE STARTING MATERIALS" APPLIED OPTICS, OSA, OPTICAL SOCIETY OF AMERICA, WASHINGTON, DC, vol. 45, no. 15, 20 May 2006 (2006-05-20), pages 3510-3515, XP001242714 ISSN: 0003-6935 abstract page 3510, left-hand column, paragraph 1 page 3514, right-hand column, lines 4-13	1-20			
	 -/				

Further documents are listed in the continuation of Box C.	X See patent family annex.	
 Special categories of cited documents: A' document defining the general state of the art which is not considered to be of particular relevance E' earlier document but published on or after the international filing date 'L' document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified) 'O' document referring to an oral disclosure, use, exhibition or other means 'P' document published prior to the international filing date but later than the priority date claimed 	 "T" later document published after the International filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention "X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone "Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art. "&" document member of the same patent family 	
Date of the actual completion of the international search	Date of mailing of the international search report	
23 juin 2009	01/07/2009	
Name and mailing address of the ISA/	Authorized officer	
European Patent Office, P.B. 5818 Patentlaan 2 NL – 2280 HV Rijswijk Tel. (+31-70) 340-2040, Fax: (+31-70) 340-3016	Ekoué, Adamah	

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International application No
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C(Continua	PCT/FR2008/001427 (Continuation). DOCUMENTS CONSIDERED TO BE RELEVANT					
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A	US 2007/017438 A1 (XIE YA-HONG [US] ET AL) 25 January 2007 (2007-01-25) page 2, paragraph 29 page 3, paragraph 38 - page 4, paragraph 42 figures 2A-2E	1-20				
	RAY S. K. ET AL.: "Effect of reactive-ion bombardment on the properties of silicon nitride and oxynitride films deposited by ion-beam sputtering" JOURNAL OF APPLIED PHYSICS,	1-20				
•	vol. 75, no. 12, 15 June 1994 (1994-06-15), pages 8145-8152, XP002484791 abstract figure 1					
A	US 6 548 375 B1 (DE LOS SANTOS HECTOR J [US] ET AL) 15 April 2003 (2003-04-15) column 3, lines 53-59	1-20				
Α .	US 5 753 038 A (VICHR MIROSLAV [US] ET AL) 19 May 1998 (1998-05-19) column 10, lines 18-29	1-20				
A	MOTOHIRO T ET AL: "GEOMETRICAL FACTORS OF ARGON INCORPORATION IN SIO2 FILMS DEPOSITED BY ION BEAM SPUTTERING" THIN SOLID FILMS, ELSEVIER-SEQUOIA S.A. LAUSANNE, CH, vol. 120, no. 4, 1 October 1984 (1984-10-01), pages 313-327, XP000837083 ISSN: 0040-6090 abstract	1-20				
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Information on patent family members

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